

## Supporting Information

# Layering technique for achieving pinhole-free organic-inorganic halide perovskite thin films through vapor-solid reaction

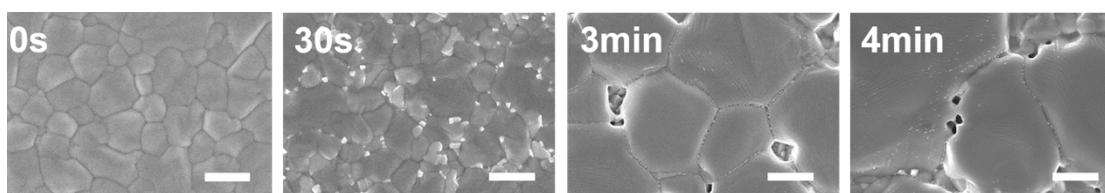
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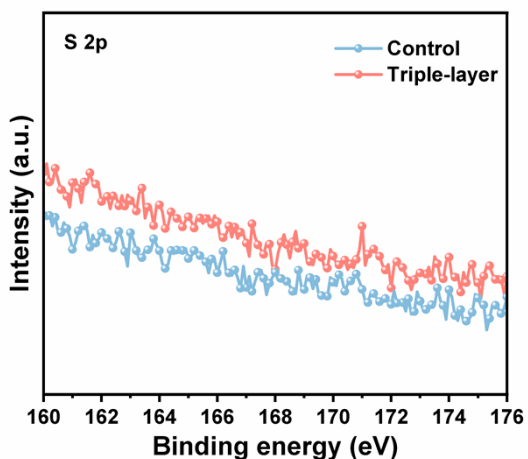
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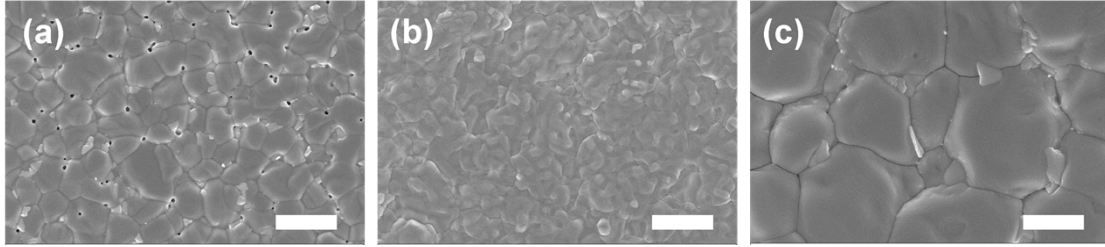
**Keywords:** Lead halide perovskite; Pinhole-free; Vapor-solid reaction; thin film; Layering technique



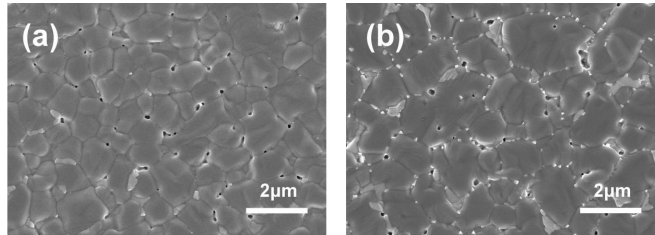
**Figure S1.** Scanning electron microscope (SEM) images of the perovskite thin films with different reaction times in FASCN vapor. Scale bar, 1 μm.



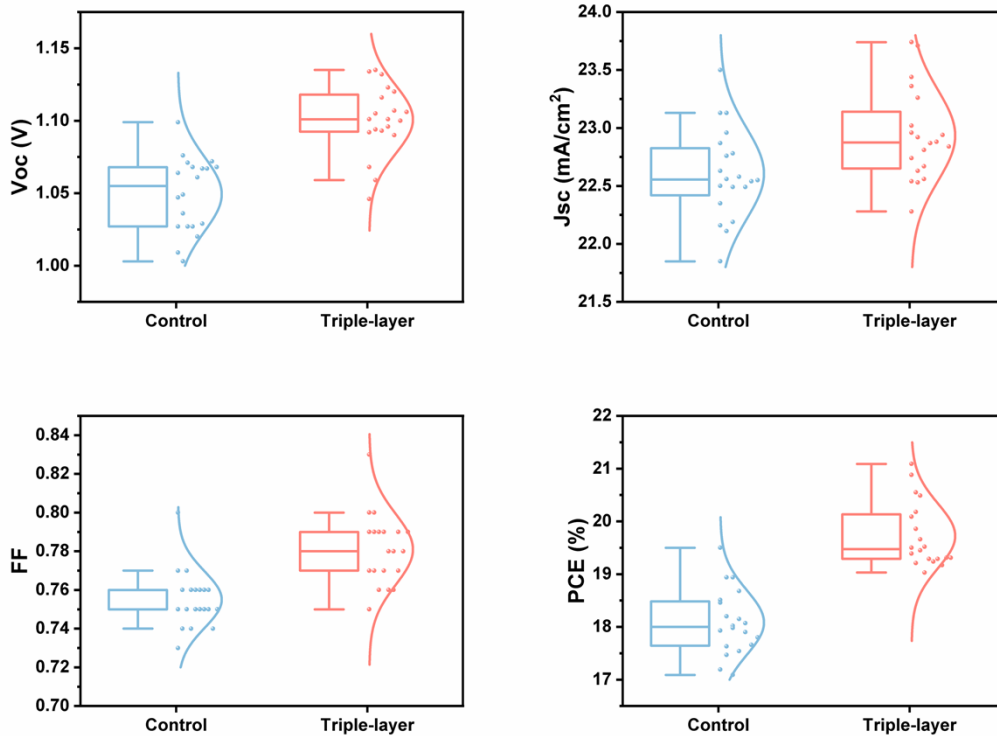
**Figure S2.** XPS spectra of the S 2p signal in the perovskite thin film with control and triple-layer.



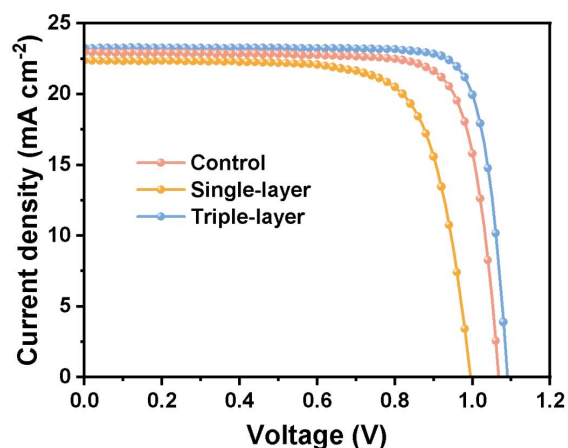
**Figure S3.** Scanning electron microscope (SEM) images during the preparation of double-layer perovskite thin films. (a) 300 nm perovskite thin film treated with FASCN vapor, (b) 300nm FASCN-perovskite/ 300 nm vapor-solid perovskite, (c) 300 nm FASCN-perovskite/300 nm FASCN-perovskite. Scale bar, 2  $\mu\text{m}$ .



**Figure S4.** SEM images of the FASCN vapor-treated films (a) unannealed and (b) annealed.



**Figure S5.** Statistics of the photovoltaic parameters distribution for solar cells based on control and triple-layer perovskite, 20 independent cells are fabricated for each type.



**Figure S6.** J-V curves of devices based on different layers of thin films

**Table S1.** Biexponential fitted TRPL parameters of the control and triple-layer samples.

Samples	$A_1$	$\tau_1$ (ns)	$A_2$	$\tau_2$ (ns)	$\tau_{avg}$ (ns)
Control	0.503	7.30	0.423	154.26	146.43
Triple-layer	0.510	7.85	0.424	318.48	309.54

**Table S2.** J-V parameters of the champion devices measured from forward scan (FS) and reverse scan (RS).

Champion device		$V_{oc}$ (V)	$J_{sc}$ (mA cm <sup>-2</sup> )	FF	PCE (%)
Control	RS	1.068	22.96	0.80	19.50
	FS	1.047	22.76	0.76	18.20
Triple-layer	RS	1.090	23.26	0.83	21.09
	FS	1.088	23.15	0.80	20.06

**Table S3** Photovoltaic parameters of devices based on different layers of films.

Device	$V_{oc}$ (V)	$J_{sc}$ (mA cm <sup>-2</sup> )	FF	PCE (%)
Control	1.068	22.96	0.80	19.50
Single-layer	0.995	22.35	0.74	16.42
Triple-layer	1.090	23.26	0.83	21.09

**Table S4** EIS Fitting parameters of solar cells based on control and triple-layer modified devices. The series resistance ( $R_s$ ) and charge composite resistance ( $R_{rec}$ ) can be obtained by data fitting of equivalent circuit diagram of PSCs by EC-Lab software.

<b>Samples</b>	<b><math>R_s</math> (<math>\Omega</math>)</b>	<b><math>R_{rec}</math> (k<math>\Omega</math>)</b>
Control	9.962	2.988
Triple-layer	9.379	6.978